



**ASSIGNMENT FOR APPLICATION FOR PATENT**

WHEREAS:

Names and Addresses of Inventors:

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<b>5)</b>	Allen L. D'Ambra 539 Francisco Drive Burlingame, CA 94010	<b>6)</b>	Yeuk-Fai Edwin Mok 194 Stone Crest Drive San Francisco, CA 94132
<b>7)</b>	Harald Herchen 927 Lundy Ln Los Altos, CA 94024		

(hereinafter referred to as Assignors), have invented a certain invention entitled:

**METHOD FOR REMOVING ELECTROLYTE FROM ELECTRICAL CONTACTS AND WAFER TOUCHING AREAS**

for which application for Letters Patent in the United States was filed on \_\_\_\_\_,  
under Serial No. \_\_\_\_\_, executed on even date herewith; and

WHEREAS, Applied Materials, Inc., a corporation of the State of Delaware, having a place of business at 3050 Bowers Avenue, Santa Clara, California 95054 (hereinafter referred to as Assignee), is desirous of acquiring the entire right, title and interest in and to said application (hereinafter referred to as Application), and the invention disclosed therein (hereinafter referred to as Invention), and in and to all embodiments of the Invention, heretofore conceived, made or discovered by said Assignors, and in and to any and all patents, inventor's certificates and other forms of protection (hereinafter referred to as Patents) thereon granted in any and all countries and groups of countries.

NOW, THEREFORE, in consideration of good and valuable consideration acknowledged by said Assignors to have been received in full from said Assignee:

1. Said Assignors hereby sell, assign, transfer and convey to Assignee the full and exclusive right, title and interest (a) in and to said Application and said Invention; (b) in and to all rights to apply for patents on said Invention in any and all countries pursuant to the International Convention for the Protection of Industrial Property or otherwise; (c) in and to any and all

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